Tool ID: 705
Tool Location: 103

Equipment Information Sheet

Hot Phosphoric Tank

Manager: Phil Infante 607-254-4926
Backup: Christopher Alpha 607-254-4913

Calls to staff phones will be automatically forwarded to their cell phones during accessible hours. At other times leave a message or send them an email.

SAFETY

- Follow all standard lab policies for use of chemicals
- System uses boiling phosphoric acid! Wear protective equipment when working at hood!
- When acid is boiling it gives off a significant amount of acid fumes. Open lid slowly to avoid acid fume exp

USAGE RESTRICTIONS
SCHEDULING/SIGN-UP RESTRICTIONS

Minimum Tool Time: 0 minutes

- None

MATERIALS COMPATIBILITY CATEGORY

Tool Category 1E: Silicon Based Materials and Select Dieletrics

Allowed	Not Allowed
Silicon Based Materials only	No Evaporated or Sputtered Films
Si, SiC, SiO_2 substrates	No Metal or Organic Films
All Furnace grown or deposited films	No Glass Substrates
PECVD Films	No III/V Compound Semiconductors
Select ALD dieletrics (SiO_2, SiN, HfO_2, HFN)	No High Vapor pressure materials
Spin on Glass and Spin on Dopants	Organic/Biology Molecules prepared-with or without Salt buffers

High Vapor Pressure Metals and Compounds are materials that have a vapor pressure above 1e-6 Torr at 400 C.

Additional Material Restrictions and Exceptions

- Silicon nitride etching only - no metal etching
- Teflon boats only!

Last Updated: 03/20/2019